## **IN THE CLAIMS:**

Please amend and re-number claims 9-20 and add claims 20-25 as follows.

1. (Original): A liquid crystal display device comprising:
a pair of substrates,
a liquid crystal layer interposed between said pair of substrates,
a wiring having a stacked structure layer formed on one of said pair of
substrates,
a transparent conductive film formed over said wiring,
said wiring includes a first layer of aluminum or an alloy comprising
essentially of aluminum, and at least a second layer of material selected from the group
including of molybdenum, aluminum, chromium, tungsten, silver, and copper.
2. (Original): The liquid crystal display device according to claim 1
wherein said second layer is formed on said first layer.
3. (Original): The liquid crystal display device according to claim 1
wherein said transparent conductive film includes at least one of: ITO, IZO and IGO.
4. (Original): The liquid crystal display device according to claim 1
further including a plurality of pixel parts being constructed with a plurality of gate lines
and a plurality of drain lines arranged in a matrix on one of said pair of substrates, and a
switching element being provided in each of said pixel parts,
wherein one of said plurality of drain lines comprises said wiring.
5. (Original): The liquid crystal display device according to claim 1
further including a plurality of pixel parts being constructed with a plurality of gate lines
and a plurality of drain lines arranged in a matrix on one of said pair of substrates, and a
switching element being provided in each of said pixel parts,
wherein one of said plurality of gate lines comprises said wiring.

l	6. (Original): The liquid crystal display device according to claim 5
2	wherein said plurality of gate lines are formed along a first direction in one of said pair of
3	substrates, said plurality of drain lines formed along a second direction in one of said pair
4	of substrates, a plurality of counter voltage signal lines formed along the first direction in
5	one of said pair of substrates,
6	wherein said one of plurality of counter voltage signal lines comprises said
7	wiring.
l	7. (Original): The liquid crystal display device according to claim 6
2	further including a counter electrode disposed in said pixel part and connected with said
3	one of plurality of counter voltage signal lines, said counter electrode having a rectilinear
4	shape or a comb shape.
ŀ	98. (Re-numbered): The liquid crystal display device according to
2	claim 7 further including a comb-shape pixel electrode disposed in said pixel part and
3	connected with said switching element.
1	109. (Re-numbered and Currently amended): The liquid crystal display
2	device according to claim 9-8 further including an insulation layer, wherein said counter
3	electrode is formed on one of said pair of electrodes substrates, said insulating layer is
4	formed over said counter electrode, said pixel electrode is formed on said insulating
5	layer.
1	1110. (Re-numbered and Currently amended): The liquid crystal display
2	device according to claim 9-8 further including a scan signal applied through one of said
3	plurality of gate lines to said switching element, a video signal is applied through one of
4	said plurality of drain lines and said switching element to said pixel electrode, said
5	switching element formed proximate to a crossing point between said one of said of drain
6	lines and said one of said gate lines.

1	1211. (Re-numbered and Currently amended): The liquid crystal display
2	device according to claim 9-8 wherein said pixel electrode has a zigzag-shaped structure.
1	1312. (Re-numbered and Currently amended): The liquid crystal display
2	device according to claim 9-8 wherein said pixel electrode has a comb-shaped structure.
1	1413. (Re-numbered and Currently amended): The liquid crystal display
2	device according to claim 13-12 further including an insulation layer and an organic
3	layer, wherein said counter electrode is formed on one of said pair of
4	electrodes substrates, said insulating layer is formed over said counter electrode, said
5	organic layer is formed over said insulating layer, said pixel electrode is formed on said
6	organic layer.
1	1514. (Re-numbered): A liquid crystal display device comprising:
2	a pair of substrates,
3	a liquid crystal layer interposed between said pair of substrates,
4	drain lines and gate lines formed on one of said pair of substrates and
5	crossing each other in a matrix form,
6	counter voltage lines formed on one of said pair of substrates and being
7	disposed between said gate lines,
8	wherein at least one of said drain lines, said gate lines and said counter
9	voltage lines includes a multi-layered structure covered with a transparent conductive
0	film, said multi-layered structure comprising an aluminum layer or an alloy layer
1	comprising essentially of aluminum and a high-melting point metal layer, said transparent
2	conductive film including one of ITO, IZO and IGO.
1	1615. (Re-numbered and Currently amended): The liquid crystal display
2	device according to claim 15-14 further including a pixel electrode formed on one of said
3	pair of substrates and having a comb-shaped structure, and a switching element formed

5	lines and connected with said pixel electrode.
1	1716. (Re-numbered and Currently amended): The liquid crystal display
2	device according to claim 16-15 further including a sheet of counter electrode disposed
3	on one of said pair of substrates in opposed relation to said pixel electrode and connected
4	with one of said counter voltage lines.
1	1817. (Re-numbered and Currently amended): The liquid crystal display
2	device according to claim 16-15 further including a comb-shaped counter electrode
3	disposed on one of said pair of substrates in opposed relation to said pixel electrode and
4	connected with one of said counter voltage lines.
l	1918. (Re-numbered and Currently amended): A liquid crystal display
2	device comprising:
3	a pair of substrates,
4	a liquid crystal layer interposed therebetween,
5	a thin film transistor having a gate electrode, a source electrode and a
6	drain electrode formed on one of said pair of substrates;
7	a gate line connected to said gate electrode,
8	a drain line connected to said drain electrode,
9	a pixel electrode connected to said source electrode and having an
10	approximately a slit shape structure, a comb-shaped structure, or a zigzag-shaped
11	structure,
12	a counter electrode being any of ITO, IZO or IGO and arranged in
13	opposed relation to said pixel electrode,
14	a counter voltage line connected to said counter electrode,
15	wherein said counter voltage line comprising a triple-layered structure
16	including an alumina first layer, a high-melting point metal second layer, and a third layer
17	of aluminum or an alloy comprising essentially aluminum,

proximate to a crossing point between said at least one of said drain lines and said gate

18	said high-melting point metal second layer connected to said counter
19	electrode through an opening in said alumina first layer.
1	2019. (Re-numbered and Currently amended): The liquid crystal display
2	device according to claim 19-18 wherein said alumina first layer and said high-melting
3	point metal second layer are formed on said third layer, and
4	said high-melting point metal second layer formed through said alumina
5	layer from a surface side of a portion of said alumina layer to said third layer, and
6	connected to said counter electrode.
l	20. (New): a liquid crystal display device comprising:
2	a pair of substrates and a liquid crystal layer interposed therebetween;
3	a thin film transistor having a gate electrode, a source electrode, and a
4	drain electrode formed on one of said pair of substrates;
5	a gate line connected to said gate electrode;
6	a drain line connected to said drain electrode;
7	a pixel electrode connected to said source electrode and having an
8	approximately a slit-shaped structure, a comb-shaped structure, or a zigzag-shaped
9	structure;
10	a counter electrode comprising one ITO, IZO, and IGO, and arranged in
11	opposed relation to said pixel electrode;
12	a counter voltage line connected to said counter electrode,
13	wherein said counter voltage line comprises a triple-layered structure
14	including a molybdenum or a titanium first layer, an aluminum second layer, and a
15	molybdenum or titanium third layer.
1	21. (New): The liquid crystal display device according to claim 20
2	wherein said first layer is connected to said counter electrode.

1	22. (New): The fiquid crystal display device according to claim 21
2	wherein a width of said first layer is greater than a width of said third layer.
1	23. (New): A liquid crystal display device comprising:
2	a pair of substrates and a liquid crystal layer interposed therebetween;
3	a thin film transistor having a gate electrode, a source electrode and a
4	drain electrode formed on one of said pair of substrates;
5	a gate line connected to said gate electrode;
6	a drain line connected to said drain electrode;
7	a pixel electrode connected to said source electrode;
8	a counter electrode being one of ITO, IZO, and IGO, and arranged in
9	opposed relation to said pixel electrode;
0	a counter voltage line connected to said counter electrode,
1	wherein said counter voltage line comprises a triple-layered structure
2	including a molybdenum or a titanium first layer, an aluminum second layer, and a
3	molybdenum or titanium third layer,
4	at least one of said pixel electrode and said counter electrode having an
5	approximately a slit-shaped structure, a comb-shaped structure, or a zigzag-shaped
6	structure
l	24. (New): The liquid crystal display device according to claim 23
2	wherein said first layer is connected to said counter electrode.
1	25. (New): The liquid crystal display device according to claim 24
2	wherein a width of said first layer is greater than a width of said third layer.